	Application No.	Applicant(s)
	10/684,374	ANDO, YOICHI
Notice of Allowability	Examiner	Art Unit
	Kevin Quarterman	2879
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to <u>08 August 2005</u> .		
2. The allowed claim(s) is/are <u>1-6</u> .		
3. ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) ☐ All b) ☐ Some* c) ☐ None of the:		
1. Certified copies of the priority documents have been received.		
2. Certified copies of the priority documents have been received in Application No		
3. Copies of the certified copies of the priority documents have been received in this national stage application from the		
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached		
1) hereto or 2) to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5 □ Notice of Informal P	atent Application (PTO-152)
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary	· · · · · · · · · · · · · · · · · · ·
_	Paper No./Mail Dat	e
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date	<u>_</u>	
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material		nt of Reasons for Allowance
	9. Other	

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DETAILED ACTION

Response to Amendment

1. Applicant's amendment and remarks received 08 August 2005 have been entered and overcome the objections and 112 rejections cited in the previous office action.

Allowable Subject Matter

- 2. Claims 1-6 are allowed.
- 3. The following is an examiner's statement of reasons for allowance: Applicant argues that the applied prior art (Fushimi) does not teach or suggest the claimed relationships between the distances of the components. Applicant's arguments are persuasive.
- 4. Thus, regarding independent claim 1, the prior art of record neither shows or suggests an electron beam apparatus comprising, in addition to other limitations of the claim, a distance (D1) between a portion of a potential specifying plate between one opening of a plurality of openings of the potential specifying plate near the spacer and the spacer and an electron beam irradiation member and a distance (D2) between a portion of the potential specifying plate between the one opening of the potential specifying plate near the spacer and another opening of the plurality of openings of the potential specifying plate not near the spacer and the electron beam irradiation member satisfying a relationship D1 < D2. Due to their dependency upon independent claim 1, claims 3 and 5 are also allowable.

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5. Regarding independent claim 2, the prior art of record neither shows or suggests an electron beam apparatus comprising, in addition to other limitations of the claim, a distance (D3) between a portion of a potential specifying plate between one opening of a plurality of openings of the potential specifying plate near the spacer and the spacer and an electron-emitting device and a distance (D4) between a portion of the potential specifying plate between the one opening of the potential specifying plate near the spacer and another opening of the plurality of openings of the potential specifying plate not near the spacer and the electron-emitting device satisfying a relationship D3 > D4. Due to their dependency upon independent claim 2, claims 4 and 6 are also allowable.

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- 6. The structure described earlier is provided for producing a high brightness and high quality image. The design is new and unique to the art.
- 7. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Contact Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kevin Quarterman whose telephone number is (571) 272-2461. The examiner can normally be reached on M-TH (7-5:30).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimesh Patel can be reached on (571) 272-2457. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Kevin Quarterman Examiner Art Unit 2879

15 September 2005

Joseph Williams Primary Examiner Art Unit 2879